## UNITED STATES PATENT AND TRADEMARK OFFICE **CERTIFICATE OF CORRECTION**

PATENT NO.

: 6,800,426 B2

Page 1 of 1

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INVENTOR(S): Kevin B. Ray and Anthony P. Kitson

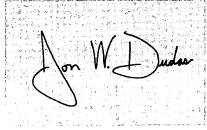
It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

## Title page,

Item [56], **References Cited**, OTHER PUBLICATIONS, "Reiser Photoreactive Polymers, The Science and Technology of Resists, Wiley-Interscience, New York, 1989, pp. 161-167." to -- Reiser, Photoreactive Polymers, The Science and Technology of Resists, Wiley-Interscience, New York, 1989, pp. 181-187 --.

Signed and Sealed this

Seventh Day of June, 2005



JON W. DUDAS
Director of the United States Patent and Trademark Office